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Electron Accumulation and Emergent Magnetism in LaMnO₃/SrTiO₃ Heterostructures

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Emergent phenomena at polar-nonpolar oxide interfaces have been studied intensely in pursuit of next-generation oxide electronics and spintronics. Here we report the disentanglement of critical thicknesses for electron reconstruction and the emergence of ferromagnetism in polar-mismatched LaMnO₃/SrTiO₃ (001) heterostructures. Using a combination of element-specific x-ray absorption spectroscopy and dichroism, and first-principles calculations, interfacial electron accumulation, and ferromagnetism have been observed within the polar, antiferromagnetic insulator LaMnO₃. Our results show that the critical thickness for the onset of electron accumulation is as thin as 2 unit cells (UC), significantly thinner than the observed critical thickness for ferromagnetism of 5 UC. The absence of ferromagnetism below 5 UC is likely induced by electron overaccumulation. In turn, by controlling the doping of the LaMnO₃, we are able to neutralize the excessive electrons from the polar mismatch in ultrathin LaMnO₃ films and thus enable ferromagnetism in films as thin as 3 UC, extending the limits of our ability to synthesize and tailor emergent phenomena at interfaces and demonstrating manipulation of the electronic and magnetic structures of materials at the shortest length scales.

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The observation of emergent interfacial electronic reconstruction and, in turn, new electronic phases at polar-nonpolar oxide interfaces have launched numerous studies on the fundamental mechanisms for and potential uses of these exotic properties [1–3]. The nature of such electronic reconstruction (used here in the broad sense as any change in valence that results from the interfacial polar mismatch) depends on many factors such as the interfacial band alignment and the conductivity of the materials that can alter the boundary conditions and thus the degree of charge compensation [4]. To date, the most widely studied system in this regard is the two-dimensional electron gas in LaAlO₃/SrTiO₃ [5]. LaAlO₃ is an insulator with a band gap of 5.6 eV that consists of alternating charged (LaO)⁺⁺ and (AlO₂)⁻ layers along the [001]. SrTiO₃ is also an insulator, with a band gap of 3.2 eV, which has neutral (SrO)⁰ and (TiO₂)⁰ layers alternating along the [001]. When these materials are brought together, a so-called polarization catastrophe is believed to occur at the (001) interface due to a potential buildup in the polar LaAlO₃, which drives charge transfer from the LaAlO₃ valence band to the SrTiO₃ conduction band at a LaAlO₃ critical thickness of 4 unit cells (UC) [6–8]. As a result, there is electron doping into the SrTiO₃ near the interface, which induces a reduction of Ti⁴⁺ towards Ti³⁺ [9] and the onset of conductivity [2]. Meanwhile, there have been reports of other exotic interfacial phenomena, such as orbital reconstruction [10], ferromagnetism [11], and superconductivity [12], and researchers have also explored the role that structural imperfections can play in the evolution of effects at these interfaces [13–17].

Since the initial observation of emergent phenomena at the LaAlO₃/SrTiO₃ heterointerface, a number of additional systems have been found to exhibit similar potential buildup-induced electronic reconstruction and interfacial phenomena (e.g., LaTiO₃/SrTiO₃ [18], LaVO₃/SrTiO₃...
L. Swei and M. R. Pederson, “Recent progress in understanding the electronic and magnetic structure of polar heterostructures,” Phys. Rev. B 90, 054414 (2014), and references therein. The heterostructures were grown on TiO$_2$-terminated SrTiO$_3$ (001) substrates by reflection high-energy electron diffraction (RHEED)-assisted pulsed-laser deposition [25]. For all films, RHEED intensity oscillations were persistent throughout the growth indicating a layer-by-layer growth mode [25]. Further characterization of the heterostructures reveals high-quality LaMnO$_3$ films with atomically smooth surfaces and high crystalline quality, and interfaces that are free of dislocations [25]. To probe the potential for electron reconstruction and associated ferromagnetic order, we have performed soft XAS and XMCD studies in a grazing incidence, total electron yield (TEY) geometry on numerous LaMnO$_3$/SrTiO$_3$ heterostructures [inset, Fig. 1(a)] [25]. Compared to previous local magnetometry studies using a scanning superconducting quantum interference device (SQUID) [23,24], the current approach is surface sensitive and provides a direct measurement of the valence state of the various elements in the films and substrates via XAS and enables the detection of subtle (~0.005 $\mu_B$/atom), element-specific magnetic moments (thus excluding magnetic impurities) via XMCD [9]. XMCD measurements at the Mn L$_{2,3}$ edges at 25 K reveal strong dichroism [Fig. 1(a)], indicative of a net ferromagnetic moment, arising from Mn in the films. XMCD of ~28% and ~26% is observed for the 9 and 12 UC thick LaMnO$_3$ films, respectively. To give this some context, the corresponding SQUID magnetometry measurement on the 9-UC-thick LaMnO$_3$/SrTiO$_3$ heterostructure revealed a magnetic moment of ~400 emu/cc at 25 K [25]. The XMCD is reduced to ~22% for the 6 UC films and finally to ~11% for the 5 UC films. There are a number of important observations to be noted here. First, due to the high sensitivity of the XMCD, we are able to detect the small magnetic moment of the 5-UC-thick films, something not accomplished in previous studies [23]. Second, the large XMCD in the LaMnO$_3$ films as thin as 9 UC is comparable to that observed in hole-doped La$_{0.67}$Sr$_{0.33}$MnO$_3$ [40].

These thickness-dependent XMCD results confirm the existence of intrinsic magnetization in the LaMnO$_3$ films.
in line with previous magnetometry studies [23,24]. To understand the nature of the magnetism, we first performed XAS measurements at both the Ti- and Mn-$L_{2,3}$ edges as a function of LaMnO$_3$ thickness to probe the corresponding evolution of the valence states. Regardless of the LaMnO$_3$ thickness, the Ti-$L_{2,3}$ edges are unchanged and match that of a SrTiO$_3$ substrate reference [Fig. 1(b)]. In other words, there is no indication of electron transfer to the SrTiO$_3$ and the bulklike character of Ti$^{4+}$ is maintained at the LaMnO$_3$/SrTiO$_3$ heterointerface. In contrast, XAS studies at the Mn-$L_{2,3}$ edges reveal marked variation with film thickness [Fig. 1(c)]. To understand the evolution of the Mn valence state, we provide spectra for bulk SrMnO$_3$ (i.e., Mn$^{4+}$ reference), LaMnO$_3$ (i.e., Mn$^{3+}$ reference), and MnO (i.e., Mn$^{2+}$ reference) for comparison [41,42]. Starting with relatively thick LaMnO$_3$ films (e.g., 12 UC), the absorption spectra are observed to be similar to that of bulk LaMnO$_3$, indicating a predominant Mn$^{3+}$ valence state. Note that the absorption peak has a slightly lower energy position than that of bulk LaMnO$_3$, indicating that the films are somewhat electron doped. Upon reducing the LaMnO$_3$ thickness (e.g., 9 UC) a shift of the main spectral feature near 641.4 eV to lower energies is observed, indicating a lower average valence state. Further reducing the LaMnO$_3$ thickness (e.g., 6, 5, and 3 UC) results in further shifts of the feature. Moreover, a strong feature near 640 eV appears that corresponds to the main absorption peak of Mn$^{2+}$. Note that the suppression of the fine feature at $\sim$638 eV in our ultrathin LaMnO$_3$ films, as compared to the MnO reference spectrum, is likely due to different local environments for the two structures [43]. Similar studies of 2-UC-thick heterostructures likewise reveal a strong feature from Mn$^{2+}$ [25]; these data are not shown on the same graph since sample charging distorts the background of the spectra. Our XAS studies clearly show that the average Mn valence state within the thin samples is reduced, and further suggest that electrons are accumulated in the LaMnO$_3$ layer near the interface starting at a critical thickness of 2 UC. This is in contrast to our above XMCD studies and the previous local magnetometry studies [23,24], which found that the emergent ferromagnetism is not measureable until a thickness 5–6 UC. That is, there is a decoupling of the electron accumulation and ferromagnetic critical thicknesses.

Furthermore, our studies are completed in TEY geometry that probes the topmost 3–5 nm of thin-film samples such that the contribution of the deeper layers to the TEY intensity decays exponentially with the distance from the film surface. Therefore, with increasing LaMnO$_3$ layer thickness the contribution of the Mn at the interface decreases accordingly. The observed decrease of Mn$^{2+}$ signatures in the Mn XAS spectra with increasing LaMnO$_3$ layer thickness suggests that the valence state is likely nonuniform along the surface normal. Thus, we find that the fraction of Mn$^{2+}$ is higher in the thinner films where the interface contributes more to the Mn XAS signal. This variation in the valence state with film thickness is also evident in the evolution of the O $K$ edge [25]. It is possible that the bottom 3 UC, near the interfacial region, remains Mn$^{2+}$ rich for the 5 and 6 UC samples [44]. As the thickness increases beyond 6 UC, the thickness becomes comparable or larger than the probing depth and the contribution from the interfacial region to the spectrum is reduced. To compensate for the polar field, the excess electrons are likely to accumulate at the interface, creating an inhomogeneous charge profile across the film thickness. Such an observation is consistent with studies of La$_{1-x}$Sr$_x$MnO$_3$/SrTiO$_3$ (001) heterostructures wherein excess electrons are found to reside near the interfaces [44].

The presence of this electron accumulation due to the polar mismatch is further supported by similar XAS studies of LaMnO$_3$/NdGaO$_3$ (110)$_O$ heterostructures (subscript $O$ denotes orthorhombic indices). The NdGaO$_3$ substrates were treated to produce Ga$_2$-terminated surfaces that are polar in nature [45]; consequently, there should be no polar mismatch at the LaMnO$_3$/NdGaO$_3$ heterointerface. XAS spectra at the Mn-$L_{2,3}$ edges are characteristic of bulklike Mn$^{3+}$ with no Mn$^{2+}$ features (even for 3-UC-thick films), and there is no thickness dependence of the XAS spectra [Fig. 1(d)]; thus, no excess charge is observed in the LaMnO$_3$/NdGaO$_3$ heterostructures. Ultimately, these studies indicate that electrons accumulate in the LaMnO$_3$ near the interfaces to alleviate the polar catastrophe in the LaMnO$_3$/SrTiO$_3$ heterostructures at film thicknesses as small as 2 UC.

To understand the origin of the electron accumulation, the band offset at the LaMnO$_3$/SrTiO$_3$ interface and the potential buildup in the LaMnO$_3$ were computed for symmetric (LaMnO$_3$)$_m$/(SrTiO$_3$)$_n$/(LaMnO$_3$)$_m$ ($n = 4, 5, 6$ UC) structures [Fig. 2(a), $m = 4$ UC] using first-principles density functional theory [25]. The resulting in-plane-averaged (oscillating blue line) and macroscopically averaged (red line) electrostatic potentials reveal a potential buildup in the LaMnO$_3$ layers due to the alternating charged atomic layers along the surface normal [Fig. 2(b), $m = 4$]. An average slope for the potential evolution was extracted for heterostructures with $m = 2, 4$ [Fig. 2(c)] from which the average internal field is determined to be $\sim$0.177 V/Å. This internal field is smaller than that reported for the LaAlO$_3$/SrTiO$_3$ system (0.24 V/Å) [7] and the difference could be due to the different screening effects of LaAlO$_3$ and LaMnO$_3$. The calculated potential buildup is based on an idealized abrupt interface without defects and adsorbates. Such a potential buildup, however, has been difficult to detect experimentally (see Figs. 35–37, Ref. [15]) and is still under debate. Additionally, by evaluating the average potential in bulk and multilayer heterostructures, the valence band offset between the LaMnO$_3$ and SrTiO$_3$ was extracted to be $\sim$0.6 eV [25]. This, combined with the large difference in band gap between LaMnO$_3$ (1.3 eV) and SrTiO$_3$ (3.2 eV) [25], results in a straddling band configuration at the
LaMnO$_3$/SrTiO$_3$ interface [Fig. 2(d)]. Based on these two facts, electron accumulation is expected to occur when the built-in potential in the LaMnO$_3$ layer surpasses the LaMnO$_3$ band gap, which is calculated to happen at a critical thickness of $\sim$7.3 Å (just less than 2 UC of LaMnO$_3$). As a result, the system will become unstable and must find a way to compensate the potential. Because the potential difference is positive from the interface to the surface, the screening or compensation effect will always tend to accumulate negative charges near the interface. This naturally explains the reduction of the Mn$^{3+}$ towards Mn$^{2+}$ in the very thin limit and near the interfaces for thicker samples. This is different from the case of LaAlO$_3$/SrTiO$_3$, where the LaAlO$_3$ band gap straddles the SrTiO$_3$ bands; thus, the negative charges stay in the SrTiO$_3$ near the interface and reduce the Ti$^{4+}$ towards Ti$^{3+}$ [7–9].

Intriguingly, no indication of Mn$^{3+}$ was detected at or near the LaMnO$_3$ film surfaces, implying that the previous proposed charge transfer model [23,24] could be over-simplified or may not be directly applicable to this system. In turn, any number of additional surface structural or chemical reconstructions could possibly occur to adequately compensate for the electron accumulation [46–49]. Furthermore, oxygen vacancies, in particular, have been considered as a means to compensate the polar field [48–50]. In these LaMnO$_3$/SrTiO$_3$ heterostructures, there is no evidence for the reduction of and oxygen vacancy formation in the SrTiO$_3$ since there was no signature of Ti$^{3+}$ detected via XAS near the interface and the heterostructures show insulating behavior [25]. Furthermore, there is no evidence for a large concentration of oxygen vacancies in either the film or substrate as a result of the growth process. This is supported by the lack of evidence for Mn$^{2+}$ in LaMnO$_3$/NdGaO$_3$ heterostructures, which, despite being fabricated at the same conditions, show no evidence of a change in the valence state. Both of these observations are consistent with the high oxygen growth pressure ($10^{-2}$ mbar) [25]. In turn, the emergence of Mn$^{2+}$ in the LaMnO$_3$/SrTiO$_3$ heterostructures is attributed to the polar discontinuity at the heterointerface regardless of the specific mechanism responsible for the electron accumulation, which could be electronic, structural, and/or chemical in nature [46–51]. Oxygen vacancies (not necessarily induced by deposition) have been proposed to be an intrinsic compensation mechanism for polar-nonpolar oxide heterostructures, which would lead to electron accumulation at the interface [48,49,51].

Bulk, stoichiometric LaMnO$_3$ with Mn$^{3+}$ is an A-type antiferromagnetic insulator [52]. Despite a possible electron-hole asymmetry in the manganite phase diagram similar to cuprates [53], the addition of either extra holes or electrons via chemical doping could lead to ferromagnetism as a result of Mn$^{3+}$-$O^{2-}$-Mn$^{4+}$ or Mn$^{3+}$-$O^{2-}$-Mn$^{2+}$ double exchange, respectively [52,54–57]. It is known that extrinsic defects, such as cation deficiency (e.g., La deficiency) or oxygen excess, could give rise to ferromagnetism in LaMnO$_3$ [58,59]. However, LaMnO$_3$ with cation deficiency or oxygen excess tends to be a ferromagnetic metal with a mixture of Mn$^{3+}$ and Mn$^{4+}$ (i.e., hole doping) [60], which is not consistent with the observation that our films are electron doped with nominal cation stoichiometry and insulating behavior [25]. Therefore, in our work, the emergence of electron doping at the LaMnO$_3$/SrTiO$_3$ interface triggered by the polar mismatch induces a mixed valence (i.e., Mn$^{2+}$/Mn$^{3+}$), which is thought to give rise to the ferromagnetic phase [52,54–57]. In fact, both the XAS and XMCD spectra observed in our relatively thick LaMnO$_3$/SrTiO$_3$
heterostructures [Figs. 1(a) and 1(c)] are similar to that of electron-doped manganites deriving their effects from chemical alloying (e.g., Ce-doped LaMnO₃), which also exhibit an insulating ferromagnetic ground state [57].

The absence of ferromagnetism for films less than 5 UC is likely due to “overaccumulation” of Mn²⁺ (stemming from the need to localize a significant number of electrons to accommodate the potential and resulting in reduced magnetization from a lack of double-exchange coupling with Mn³⁺), which favors an antiferromagnetic state [55]. In turn, we explored the possibility of reducing the Mn²⁺ component by adjusting the composition of the films to confirm our understanding of the origin of the ferromagnetism and demonstrating the potential of such systems. Previous studies have found that La vacancies give rise to hole doping in LaMnO₃ [58,60]. Thus, we have grown 5% La-deficient LaMnO₃ (La₀₉₅MnO₃) films of varying thicknesses on SrTiO₃ substrates [25] to induce holes that should act to counterdope the system under the influence of the potential and thus reduce the amount of Mn²⁺ in the ultrathin films (i.e., drive it back from an over-electron-doped state to a more “optimally doped” level). La deficiency is an effective route to introduce holes into LaMnO₃ via the defect formula (La₁₋ₓ[Vₓ/2][Laₓ]),(Mn₁₋₃ₓ,Mn₃ₓ)O₂⁻. The La₀₉₅MnO₃ exhibits alternating (La₁₋ₓ[O¹₋³ₓ]) and (Mn₁₋₃ₓ,Mn₃ₓ)O₂⁻ layers and thus a polar mismatch still exists at the La₀₉₅MnO₃/SrTiO₃ interface. Because of the La deficiency, the magnitude of the polar discontinuity would be reduced with additional holes. From XAS studies of these La₀₉₅MnO₃ films, a weaker thickness dependence of the Mn valence is observed [Fig. 3(a)]. In particular, the peak corresponding to Mn²⁺ at 639.8 eV is suppressed in the 3-UC-thick La₀₉₅MnO₃ films. In turn, subsequent XMCD studies reveal clear dichroism even in 3-UC-thick La₀₉₅MnO₃/SrTiO₃ heterostructures [Fig. 3(b)]—confirming the importance of controlling the valence state of the material to relieve the overaccumulation of electrons. All told, the observation of an insulating ferromagnetic ground state in films as thin as just 3 UC shows the power of emergent phenomena and approaches the limits of our ability to synthesize and study emergent phenomena at interfaces, and has potential applications in spin polarized tunneling devices.

To summarize, we have provided direct evidence for electron accumulation and ferromagnetism occurring within the polar, antiferromagnetic insulator LaMnO₃ when grown on nonpolar SrTiO₃. Using XAS combined with first-principles calculations, the critical thickness for the onset of electron accumulation is determined to be 2 UC. The strength of the polar mismatch can drive overdoping of the LaMnO₃, which suppresses the onset of ferromagnetism as the average valence state tips towards Mn²⁺. In stoichiometric LaMnO₃, ferromagnetism is observed in only 5-UC-thick films. In turn, through chemical doping (achieved via control of the film stoichiometry), the average valence state can be tuned, and clear ferromagnetism can be observed in La₀₉₅MnO₃ films as thin as 3 UC. Ultimately, this work demonstrates the state of the art as it pertains to ultrafine control of materials, whereby controlling both the atomic structure of interfaces and doping level, unprecedented properties and control of materials is produced.

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FIG. 3. (a) Mn L₂,₃ XAS spectra of the La₀₉₅MnO₃/SrTiO₃ heterostructures. (b) Mn XMCD spectra for the 3 UC La₀₉₅MnO₃/SrTiO₃ heterostructure. The XMCD features reverse in sign when the magnetic field is reversed, confirming the reliability of the observation.
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